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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: **Akira MATSUDA et al.**

Group Art Unit: **1775**

Serial No.: **10/719,020**

Examiner: **Robert R. Koehler**

Filed: **November 24, 2003**

Confirmation No.: **9168**

For: **PLATING BATH FOR FORMING THIN RESISTANCE LAYER,  
METHOD OF FORMATION OF RESISTANCE LAYER,  
CONDUCTIVE BASE WITH RESISTANCE LAYER, AND  
CIRCUIT BOARD MATERIAL WITH RESISTANCE LAYER**

Attorney Docket Number: **032130**

Customer Number: **38834**

**PETITION FOR EXTENSION OF TIME**

Commissioner for Patents  
P. O. Box 1450  
Alexandria, VA 22313-1450

Date: July 5, 2005

Sir:

Applicants petition the Commissioner for Patents to extend the time for response to the Office Action dated March 4, 2005 for one month from June 4, 2005 to July 4, 2005.

Attached please find a check in the amount of **\$120.00** to cover the cost of the extension.

If any additional fees are due in connection with this paper, please charge our Deposit Account No. 50-2866.

Respectfully submitted,

**WESTERMAN, HATTORI, DANIELS & ADRIAN, LLP**

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120.00 OP

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Limited Recognition

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SY/mt